



高压开发平台

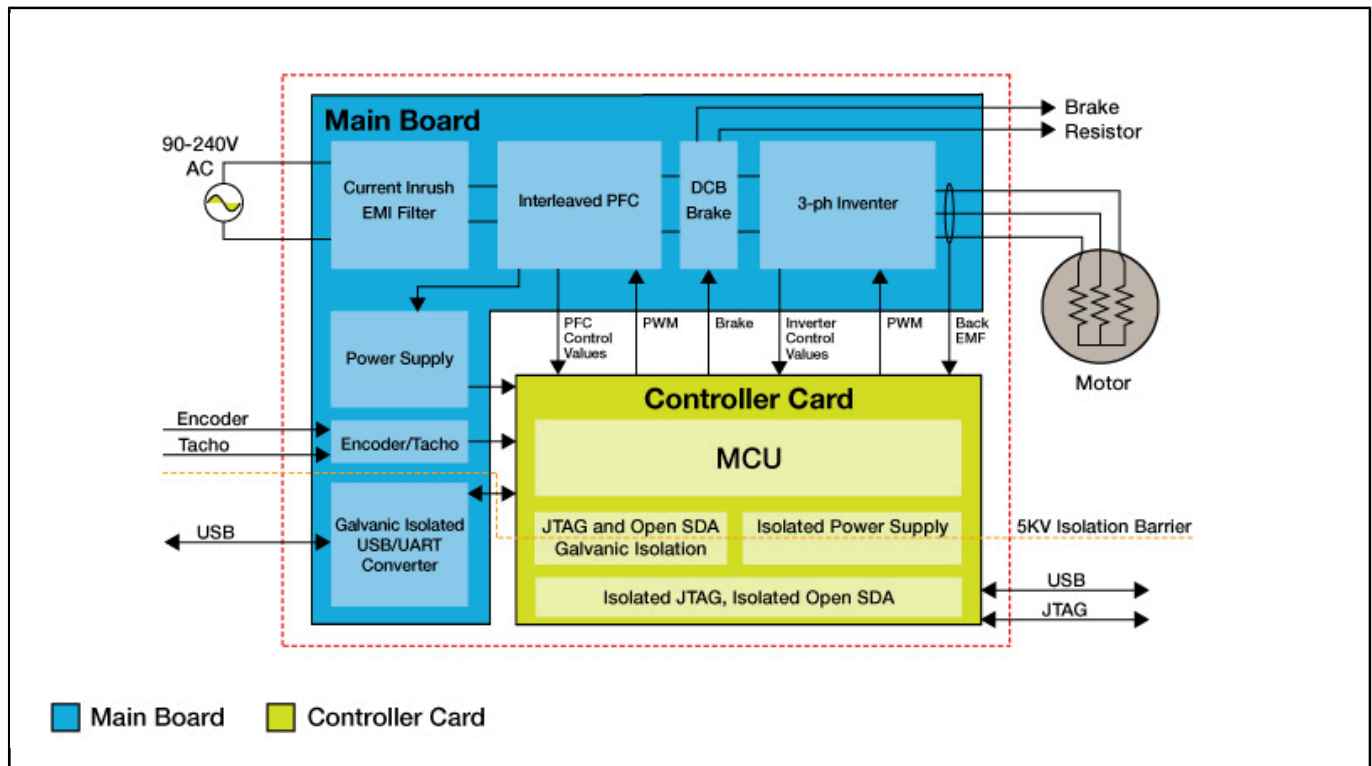
HVP-MC3PH

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恩智浦高压开发平台是一款面向Kinetis® V系列MCU、Kinetis E系列MCU和恩智浦数字信号控制器的评估和开发解决方案。

- 该平台支持在安全的高压环境下开发3相PMSM、BLDC和ACIM电机控制及功率因数校正解决方案。
- 它是一款独立的解决方案，旨在为支持恩智浦MCU的控制器卡提供开发基础。
- 该平台兼容所有Kinetis V系列MCU、Kinetis E系列MCU和DSC控制器卡。该开发平台内含HVP-KV46F150M控制器卡。

高压开发平台结构框图 Block Diagram



View additional information for [高压开发平台](#).

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